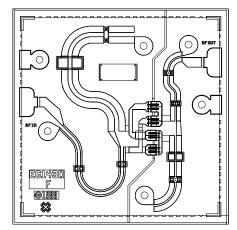


## 20 - 40 GHz X2 Frequency Multiplier

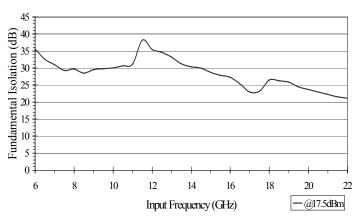
## **TGC1430F**



Chip Dimensions 1.50 mm x 1.50 mm

#### 0.0 -5.0 Conversion Gain (dB) -10.0 -20.0 - (a)17.5dBm -25.0 -30.0 10.0 18.0 22.0 6.0 8.0 12.0 14.0 16.0 20.0 Input Frequency (GHz)

Conversion Gain vs Input Frequency (Input @ 17.5dBm)



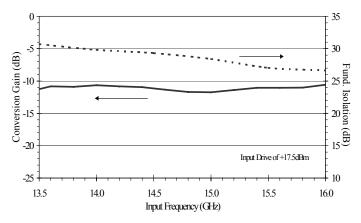
Fundamental Isolation

## **Key Features and Performance**

- 0.25um pHEMT Technology
- 20 40 GHz Output Frequencies
- 10 20 GHz Fundamental Frequencies
- -12 +/- 2dB Conversion Gain
- 18 dBm Input Drive Optimum
- 25dB Fundamental Isolation

## **Primary Applications**

- Point-to-Point Radio
- Point-to-Multipoint Communications



Conversion Gain and Fundamental Isolation for 27 - 32 GHz Output

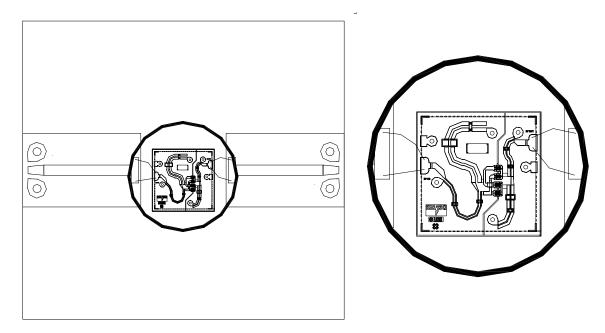
Note: Devices designated as EPU are typically early in their characterization process prior to finalizing all electrical and process specifications. Specifications subject to change without notice



## **Advance Product Information**

August 29, 2000

**TGC1430F** 



TGC1430F - Recommended Assembly Drawing



# **Advance Product Information**

August 29, 2000

**TGC1430F** 

## **Assembly Process Notes**

#### Reflow process assembly notes:

- AuSn (80/20) solder with limited exposure to temperatures at or above 300°C
- alloy station or conveyor furnace with reducing atmosphere
- no fluxes should be utilized
- coefficient of thermal expansion matching is critical for long-term reliability
- storage in dry nitrogen atmosphere

### Component placement and adhesive attachment assembly notes:

- vacuum pencils and/or vacuum collets preferred method of pick up
- avoidance of air bridges during placement
- force impact critical during auto placement
- organic attachment can be used in low-power applications
- curing should be done in a convection oven; proper exhaust is a safety concern
- microwave or radiant curing should not be used because of differential heating
- coefficient of thermal expansion matching is critical

### Interconnect process assembly notes:

- thermosonic ball bonding is the preferred interconnect technique
- force, time, and ultrasonics are critical parameters
- aluminum wire should not be used
- discrete FET devices with small pad sizes should be bonded with 0.0007-inch wire
- maximum stage temperature: 200 ° C

GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.

Note: Devices designated as EPU are typically early in their characterization process prior to finalizing all electrical and process specifications. Specifications are subject to change without notice.